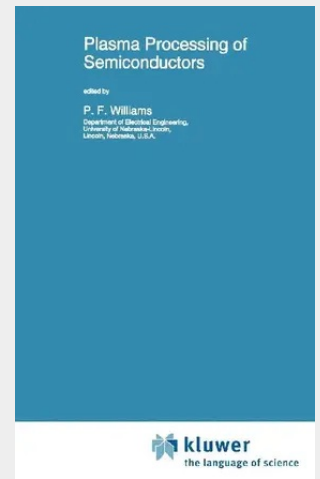


Plasma Processing of Semiconductors

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320,99 €

299,99 € (zzgl. MwSt.)

Lieferfrist: bis zu 10 Tage

Artikelnummer: 9780792345671

Medium: Buch

ISBN: 978-0-7923-4567-1

Verlag: Springer

Erscheinungstermin: 31.05.1997

Sprache(n): Englisch

Auflage: 1997

Serie: NATO Science Series E:

Produktform: Gebunden

Gewicht: 1098 g

Seiten: 613

Format (B x H): 160 x 241 mm

